

Title (en)

RADICALLY POLYMERISABLE COMPOSITIONS CONTAINING MONOFUNCTIONAL MONOMERS, RESINS AND OPHTHALMIC ARTICLES OBTAINED FROM THEM, NEW MONOFUNCTIONAL MONOMERS

Title (de)

RADIKALISCH POLYMERISIERBARE ZUSAMMENSETZUNGEN ENTHALTEND MONOFUNKTIONELLE MONOMERE, DARAUS ERHÄLTLICHE KUNSTSTOFFE UND OPHTHALMISCHE GEGENSTÄNDE, NEUE MONOFUNKTIONELLE MONOMERE

Title (fr)

COMPOSITIONS A POLYMERISATION RADICALAIRE CONTENANT DES MONOMERES MONOFONCTIONNELS, RESINES ET ARTICLES OPHTALMIQUES OBTENUS A PARTIR DE CELLES-CI, NOUVEAUX MONOMERES MONOFONCTIONNELS

Publication

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Application

**EP 01956448 A 20010529**

Priority

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- FR 0006988 A 20000531

Abstract (en)

[origin: WO0192372A2] The aim of the present invention is: radically polymerisable compositions which contain at least one monofunctional monomer with at least one difunctional monomer; resins which are obtainable by radical copolymerisation of said compositions; it being possible for the resins to be photochromic or not; articles, notably ophthalmic articles, which are constituted totally or in part of such resins; new monofunctional monomers.

IPC 1-7

**C08G 65/333; C07C 271/12; G02B 1/04**

IPC 8 full level

**G02C 7/00** (2006.01); **C07C 271/16** (2006.01); **C08F 212/08** (2006.01); **C08F 212/14** (2006.01); **C08F 212/34** (2006.01); **C08F 220/10** (2006.01); **C08F 220/20** (2006.01); **C08F 222/10** (2006.01); **C08G 65/26** (2006.01); **C08G 65/332** (2006.01); **G02B 1/04** (2006.01); **G02B 5/23** (2006.01)

CPC (source: EP KR US)

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Citation (examination)

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- EP 0471972 A2 19920226 - BASF CORP [US]
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DOCDB simple family (publication)

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